

### Policies and Review Topics for Exam #3

The following policies will be in effect for the exam. They will be included in a list of instructions and policies on the first page of the exam:

1. You will be allowed to use a non-wireless enabled calculator, such as a TI-99.
2. You will be allowed to use three 8.5 × 11-inch two-sided handwritten help sheets. No photocopied material or copied and pasted text or images are allowed. If there is a table or image from the textbook or some other source that you feel would be helpful during the exam, please notify me.
3. All help sheets will be collected at the end of the exam but will be returned to you later.
4. **You may not leave the exam room without prior permission except in an emergency or for an urgent medical condition. Please use the restroom before the exam.**

The following is a list of topics that could appear in one form or another on the exam. Not all of these topics will be covered, and it is possible that an exam problem could cover a detail not specifically listed here. However, this list has been made as comprehensive as possible. You should be familiar with the topics on the previous review sheets in addition to those listed below.

Although significant effort has been made to ensure that there are no errors in this review sheet, some might nevertheless appear. The textbook is the final authority in all factual matters, unless errors have been specifically identified there. You are ultimately responsible for obtaining accurate information when preparing for the exam.

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Three-terminal voltage regulators (like the LM117 and LM317)

$$\text{- load regulation} = \frac{\Delta v_o}{\Delta i_L},$$

where  $\Delta v_o$  is change in output voltage for given change in load current  $\Delta i_L$  for constant regulator input voltage  $v_I$  (“output” and “load” refer to the same thing)

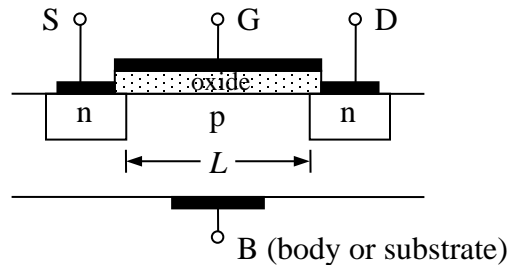
- conversion of load regulation unit used in datasheets to the mV/mA unit
- load regulation is essentially the Thévenin equivalent (internal) resistance of the output port of the regulator
- load regulation is effectively increased by the resistance of the conductor (such as a circuit board trace) between the regulator output and the load; stray resistance of the output conductor degrades load regulation by increasing its value
- line regulation =  $\frac{\Delta v_o}{\Delta v_I}$ ,

where  $\Delta v_o$  is change in output voltage for given change in line (input) voltage  $\Delta v_I$  for constant load current  $i_L$  ( $\Delta v_I$  is usually equal to the ripple on filter capacitor voltage)

- conversion of line regulation unit used in datasheets to the mV/V unit
- line regulation can be thought of as the ripple suppression or attenuation of the regulator; the ripple voltage on the filter capacitor on the input side is greatly reduced by the regulator so that the ripple voltage at the load on the output side is very small
- When  $i_L$  increases, capacitor and output ripple increase, and output voltage drops.

“MOSFET” = Metal-Oxide Semiconductor Field Effect Transistor

Internal structure of enhancement-mode MOSFET ( $n$ -channel device shown below)



- gate is insulated from doped silicon by oxide or polymer layer
- device is usually symmetrical between source and drain (i.e., drain and source have same geometrical shape and size)
- channel lies inside substrate between source and drain regions and is usually only microns or a fraction of a micron in length (1 micron =  $10^{-6}$  m)
- as of 2014, smallest channel length in commercially available FETs was 32 nm (p. 254 of Sedra & Smith, 7<sup>th</sup> ed.); 8<sup>th</sup> ed. lists a 28 nm process technology node
- $L$  = channel length (inside distance from source to drain);  $W$  = channel width
- $W/L$  = “aspect ratio”; usually,  $W > L$

Qualitative understanding of operation of enhancement-mode MOSFET & fundamentals

- threshold voltage  $V_t$
- effect of increasing  $v_{GS}$  (charge carriers flood region under gate insulation as  $v_{GS}$  rises above  $V_t$ , which forms channel); this is the reason for “enhancement” part of device name
- effect of increasing  $v_{DS}$  (channel bottom tilts as  $v_{DS}$  rises to a value comparable to  $v_{GS}$ )
- directions and polarities of important currents and voltages (e.g.,  $i_D$  and  $v_{DS}$ )
- do not confuse drain current  $i_D$  in MOSFET with diode current  $i_D$  (context)
- depletion region around drain
- pinch-off condition occurs when FET is in saturation (constant-current) region; current still flows, but it does not continue to increase much with increasing  $v_{DS}$
- electron and hole mobilities are dependent on process technology used (see Appendix K in Sedra & Smith, 8<sup>th</sup> ed.); typical values for doped silicon:
  - o  $\mu_n = 216 \text{ cm}^2/\text{V}\cdot\text{s}$  (for 65 nm process) to  $550 \text{ cm}^2/\text{V}\cdot\text{s}$  (for 0.8  $\mu\text{m}$  process)
  - o  $\mu_p = 40 \text{ cm}^2/\text{V}\cdot\text{s}$  (for 65 nm process) to  $250 \text{ cm}^2/\text{V}\cdot\text{s}$  (for 0.8  $\mu\text{m}$  process)
  - o  $\mu_n$  approx. 2–4 times  $\mu_p$
- $\mu_n$  ( $\mu_p$ ) and  $V_t$  are highly temperature dependent; both decrease with increasing temp.;  $\mu_n$  ( $\mu_p$ ) usually dominates temperature behavior if  $v_{GS}$  is much larger than  $V_t$
- capacitance of gate per unit area,  $C_{ox} = \epsilon_{ox}/t_{ox}$  ( $\epsilon_{ox}$ ,  $t_{ox}$  = permittivity and thickness of oxide layer); typical values are around 1–10 fF/ $\mu\text{m}^2$
- process transconductance parameter  $k'_n = \mu_n C_{ox}$  or  $k'_p = \mu_p C_{ox}$ ; unit is  $\text{A}/\text{V}^2$
- MOSFET transconductance parameter (includes aspect ratio  $W/L$ ):

$$k_n = \mu_n C_{ox} \frac{W}{L} = k'_n \frac{W}{L} \quad \text{and} \quad k_p = \mu_p C_{ox} \frac{W}{L} = k'_p \frac{W}{L}$$

MOSFET  $i_D$ - $v$  characteristic ( $i_D$  vs.  $v_{DS}$  for selected values of  $v_{GS}$ ) & regions of operation

- cut-off region
  - o  $v_{GS} < V_t$
  - o  $i_D = 0$
- triode region
  - o  $v_{GS} > V_t$  and  $v_{DS} < v_{GS} - V_t$
  - o drain current expression for NMOS (similar for PMOS):
 
$$i_D = k_n \left[ (v_{GS} - V_t)v_{DS} - \frac{1}{2}v_{DS}^2 \right]$$
  - o if  $v_{DS} \ll v_{GS}$ , MOSFET acts as voltage-controlled resistor (similar expression for PMOS):
 
$$i_D \approx k_n (v_{GS} - V_t)v_{DS} \rightarrow \frac{v_{DS}}{i_D} = r_{DS} = \frac{1}{k_n (v_{GS} - V_t)}$$
  - o drain-to-source resistance  $r_{DS}$  is relevant only when MOSFET acts as voltage-controlled resistor or as a switch in the on state (i.e.,  $v_{DS} \ll v_{GS} - V_t$ ); it is not applicable in the saturation region
- saturation region
  - o  $v_{GS} > V_t$  and  $v_{DS} \geq v_{GS} - V_t$
  - o simple drain current expression for NMOS (similar for PMOS):
 
$$i_D = \frac{1}{2}k_n (v_{GS} - V_t)^2$$
  - o more accurate form that includes channel-length modulation:
 
$$i_D = \frac{1}{2}k_n v_{OV}^2 [1 + \lambda(v_{DS} - v_{OV})] \approx \frac{1}{2}k_n v_{OV}^2 (1 + \lambda v_{DS}), \text{ where } v_{OV} = v_{GS} - V_t$$

## General analysis techniques for MOSFET circuits

- determination of region of operation (cutoff, saturation, or triode)
  - o first determine whether  $v_{GS} > V_t$  if possible
  - o assume region of op., analyze circuit, then check assumption
  - o if MOSFET is not cut off, it's usually easiest to assume saturation initially
- $v_{DS}$  for  $n$ -channel MOSFETs is typically positive (negative for PMOS), although it can be close to zero for MOSFETs used in digital logic gates
- graphical analysis techniques (load lines) can be applied but are rarely used now
- resolution of sign ambiguities when quadratic formula is required due to square-law dependence of  $i_D$  on  $v_{GS}$  (or  $v_{DS}$  in triode region)

## General amplifier concepts and background

- "analog" vs. "digital" electronics
- linear vs. nonlinear regions of operation
- concept of a signal; voltage and current signals
- concept of a circuit "port" (pair of terminals)
- concepts of signal sources and loads (TEC/NEC of a source includes a V or I source; TEC/NEC of a load contains no V or I source; both include equivalent resistance)
- distinguishing characteristics of "good" voltage amplifiers (very high input resistance and very low output resistance)

## Distinctions between bias, signal, and total voltages and currents; basics of amplification

- signals are usually time-varying, but don't have to be
- signals contain information (e.g., audio, video, encoded digital data, or sensor outputs proportional to physical quantities like temperature, pressure, or humidity, etc.)
- bias conditions (DC levels) define the "Q-point" (quiescent point or no-signal condition)

- total voltage or current is sum of bias and signal components (superposition)
- conventions:
  - o lower-case variable w/upper-case subscript: total (bias + signal) quantity
  - o upper-case variable w/upper-case subscript: bias (quiescent) quantity
  - o lower-case variable w/lower-case subscript: signal (time-varying) quantity

### Fundamentals of MOSFET amplifier circuits

- gate terminal insulated from substrate of MOSFET; bias and signal gate currents are zero
- voltage transfer characteristic (VTC)
  - o plot of output voltage vs. input voltage
  - o graphically expresses transfer function of MOSFET amplifier circuit
- most MOSFET amplifiers require the MOSFET to operate in the saturation region
- basic definition of small-signal voltage gain  $A_v$  (for NMOS devices; similar for PMOS; one of several ways to determine it)

$$A_v = \left. \frac{\partial v_o}{\partial v_{IN}} \right|_{v_{GS}=V_{GS}} \quad \text{or} \quad A_v = \left. \frac{\partial v_o}{\partial v_{IN}} \right|_{v_{IN}=V_{INQ}},$$

where  $V_{GS}$  is the quiescent gate-to-source voltage and  $V_{INQ}$  is the quiescent input voltage

- for common-source (CS) inverter circuit with  $R_S$  bypassed by capacitor,

$$A_v = \frac{dv_o}{dv_{IN}} = \frac{dv_{DS}}{dv_{GS}} = \frac{d}{dv_{GS}} \left[ V_{DD} - \frac{1}{2} k_n R_D (v_{GS} - V_t)^2 \right] = -k_n R_D (v_{GS} - V_t)$$

Note that gain is nonlinear (a function of  $v_{GS}$ ) but is approximately linear if variation of  $v_{GS}$  is limited to a small range of values centered on the quiescent value  $V_{GS}$  such that  $|v_{gs}| \ll 2(V_{GS} - V_t) = 2 V_{OV}$ ; this is called the *small-signal condition*.

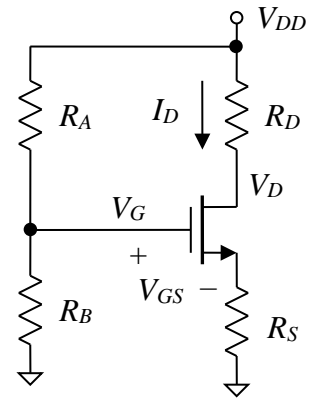
- Superposition can be applied to perform DC bias analysis and small-signal analysis separately; it greatly simplifies analysis in most cases.

### Biasing MOSFET circuits

- concept of biasing and why it is necessary
- parameters  $k_n$ ,  $k_p$ , and  $|V_t|$  usually exhibit wide variability from device to device due to loose manufacturing tolerances
- parameters  $k_n$ ,  $k_p$ , and  $|V_t|$  decrease with increasing temperature (strong dependence);  $|V_t|$  change is approximately  $-2 \text{ mV}/^\circ\text{C}$  ( $-2 \text{ mV}/\text{K}$ ); minus sign indicates drop in value as temperature increases (i.e., a negative temperature coefficient or tempco)
- decrease in  $|V_t|$  raises drain current, but decrease in  $k_n$  (or  $k_p$ ) lowers drain current
- change in  $V_t$  usually dominates at low overvoltages ( $V_{OV} = V_{GS} - V_t$ ), and change in  $k_n$  (or  $k_p$ ) usually dominates at high overvoltages (e.g., Fig. 5 of 2N7000 datasheet)
- variation in  $k_n$  ( $k_p$ ) is largely dominated by temperature dependence of  $\mu_n$  ( $\mu_p$ );  $\mu_n \propto T^{-2.2}$
- design for quiescent output voltage, drain current, and/or voltage drop across source resistor
- usually bias MOSFET for operation in the saturation region if it's used as amplifier
- must pay attention to swing range of  $v_D$  (total voltage) to avoid cutoff and triode regions
  - o saturation region defined by
 
$$v_{DS} \geq v_{GS} - V_t \rightarrow v_D - v_S \geq v_G - v_S - V_t \rightarrow v_D \geq v_G - V_t$$
  - o in cutoff region,  $i_D = 0$ ; also true at boundary b/w cutoff and saturation regions
  - o saturation-triode boundary defined by (for NMOS devices):
 
$$V_D \Big|_{\text{sat-triode}} = V_G - V_t \quad \text{or (equivalently)} \quad V_{DS} \Big|_{\text{sat-triode}} = V_{GS} - V_t$$

- “Four-resistor” bias network (source degeneration)

- must satisfy  $I_D = 0.5k_n(V_{GS} - V_t)^2$  and  $V_{GS} = V_G - I_D R_S$  simultaneously
- square-law relationship sometimes leads to solution of quadratic equations
- must determine which of 2 solutions to quadratic equation is the physical solution
- exact solution for drain current:



$$I_D = \frac{V_G - V_t}{R_S} + \frac{1}{k_n R_S^2} - \frac{1}{k_n R_S^2} \sqrt{1 + 2k_n R_S (V_G - V_t)}$$

- design rules of thumb:

$$I_D R_D = I_D R_S = \frac{1}{3} V_{DD} \text{ (sometimes)} \quad \text{and} \quad V_G = I_D R_S + V_t + \sqrt{2I_D/k_n} \text{ (always);}$$

$V_D$  value could be explicitly specified so that  $I_D R_D \neq \frac{1}{3} V_{DD}$ ;

value of  $I_D R_S$  might be different as well to meet other constraints

- $V_{DS}$  (or  $V_D$ ) sometimes made to exceed sat.-triode boundary by a specified amount
- establishment of gate bias voltage simplified because  $I_G = 0$ :  $V_G = V_{DD} \frac{R_B}{R_A + R_B}$ ,

where  $R_B$  is the “lower” resistor (b/w gate and ground)

#### DC blocking capacitors

- act as open circuits at DC (after transient phase when DC steady state applies)
- act as short circuits (or very low impedances or reactances) at signal frequencies
- isolate DC biasing from effects of signal source and/or load
- impedance and reactance

$$Z_C = \frac{1}{j\omega C} = \frac{1}{j2\pi fC} \quad \text{and} \quad X_C = -\frac{1}{\omega C} = -\frac{1}{2\pi fC} \quad (Z_C = jX_C)$$

#### AC bypass capacitors

- act as open circuits at DC
- act as short circuits (or very low impedances or reactances) at signal frequencies
- ensure bypassed nodes are close to ground potential at signal frequencies
- commonly connected between power supply nodes and ground and across source (FETs) or emitter (BJTs) degeneration resistors

#### Amplifier nomenclature

- common-source (CS) amplifier is the basic MOSFET inverting amplifier
- common-drain (CD) amplifier is noninverting with a gain close to or less than one; usually called a *source follower* [CD amps not on Exam #3]
- “common” refers to terminal connected either directly to ground or indirectly to ground through a few resistors, capacitors, and maybe inductors. The signal source and the load are connected to other terminals and have the common terminal in common.
- CS amps and source followers can be biased in multiple ways (e.g., 4-R network, drain-to-gate feedback resistor, current mirror); the biasing network does not determine the amplifier’s nomenclature.

## General small-signal modeling of MOSFET circuits

- definition of “incremental signal” or “small signal” (fluctuations are a small fraction of total voltage or current)
- small-signal condition for MOSFETs:  $|v_{gs}| \ll 2(V_{GS} - V_t)$
- separation of bias considerations (quiescent levels; output voltage swing range) from small-signal considerations (gain, input and output resistance)
- for small-signal analysis using superposition,
  - o replace transistors with their appropriate hybrid-pi models
  - o replace DC voltage sources with shorts (because voltage across a DC voltage source can't change; alternative reason: a 0-V source is a signal short)
  - o replace DC current sources with opens (because current through a DC current source can't change; alternative reason: a 0-A source is a signal open)
  - o replace large capacitors with shorts (if capacitive reactance is insignificant at operating frequency)
  - o replace small capacitors/capacitances with opens (if capacitive reactance is enormous at operating frequency)
  - o replace large inductors with opens (if inductive reactance is very large at operating frequency)
  - o replace small inductors/inductances with shorts (if inductive reactance is insignificant at operating frequency)
- DC voltage sources are typically bypassed at AC (i.e., at signal frequencies) using large capacitors to ensure that the DC source acts as an AC ground.
- small-signal model of MOSFET (hybrid pi model)
  - o voltage-controlled current source  $g_m v_{gs}$
  - o output resistance  $r_o$  due to channel-length modulation
  - o gap (open) b/w gate and source
  - o hybrid pi model only valid when device operates in the saturation region
- small-signal model of drain-to-source path represented by  $r_{DS}$  is only valid when MOSFET operates in the low- $v_{DS}$  triode (resistive) region; i.e.,  $v_{DS} \ll v_{GS} - V_t$
- small-signal model of MOSFET in cut-off region consists of open circuits between all terminals (gate, source, drain)
- derivation of small-signal voltage gain  $v_o/v_{in}$  (or  $v_o/v_{sig}$  sometimes)
- simplifications can sometimes be made in gain expressions when one term is much greater/smaller than another term
- small-signal transconductance  $g_m$  (for NMOS devices; similar for PMOS)

- o basic definition:  $g_m = \left. \frac{\partial i_D}{\partial v_{GS}} \right|_{v_{GS}=V_{GS}}$ ; can be derived from

$$I_D + i_d = \frac{1}{2} k_n (V_{GS} + v_{gs} - V_t)^2 = \frac{1}{2} k_n (V_{GS} - V_t)^2 + k_n (V_{GS} - V_t) v_{gs} + \frac{1}{2} k_n v_{gs}^2$$

$$\approx \frac{1}{2} k_n (V_{GS} - V_t)^2 + k_n (V_{GS} - V_t) v_{gs}$$

$$\rightarrow i_d = k_n (V_{GS} - V_t) v_{gs} = g_m v_{gs} \quad \text{and} \quad I_D = \frac{1}{2} k_n (V_{GS} - V_t)^2,$$

where  $|v_{gs}| \ll 2(V_{GS} - V_t)$  and  $g_m = k_n (V_{GS} - V_t)$

- o equivalent formulas (for NMOS devices; similar for PMOS):

$$g_m = k_n V_{OV} = k_n (V_{GS} - V_t) = \frac{2I_D}{V_{GS} - V_t} = \sqrt{2k_n I_D}, \quad \text{where } k_n = k'_n \frac{W}{L} = \mu_n C_{ox} \frac{W}{L}$$

Relevant course material:

HW: #7 and #8

Labs: #4

Readings: Assignments from Oct. 18 through Nov. 8 (but not the MOSFET output resistance  $r_o$  due to channel-length modulation), including the lecture notes:  
 “Three-Terminal Linear Voltage Regulators” (line/load regulation sections)  
 “Source Degeneration Biasing for Discrete MOSFET Amplifiers”

This exam will focus primarily on the course outcomes listed below and related topics:

4. Analyze and/or design power supply circuits using linear voltage regulators. [only line and load regulation]
5. Determine the region of operation of a MOSFET or BJT. [MOSFET only]
6. Determine and/or set the bias point (quiescent operating point) of a MOSFET or BJT circuit. [MOSFET only]
7. Find transfer functions of basic MOSFET and/or BJT amplifier circuits, switching circuits, and digital logic circuits. [common-source amplifier only]

For all four outcomes, the focus will be only on circuits involving MOSFETs. For outcome #7, the focus will be mostly on variations of the common-source amplifier circuit. There will be no problems involving PMOS ( $p$ -channel MOSFET) devices.

The course outcomes are listed on the Course Policies and Information sheet, which was distributed at the beginning of the semester and is available on the Syllabus and Policies page at the course web site. The outcomes are also listed on the Course Description page. Note, however, that some topics not directly related to the course outcomes could be covered on the exam as well.